

Group Art Unit
Examiner:
Atty. Dkt.

1753

R. Zervigon

P

0272798

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Client Ref

Appl. Title:

PLASMA PROCESSING APPARATUS,
AND ELECTRODE STRUCTURE AND
TABLE STRUCTURE OF
PROCESSING APPARATUS

Date: October 5, 2002

Inventor(s): Mitsuaki KOMINO et al.

Appl. No.: 09 667,770

Series Code ↑

Serial No. ↑

Filed: September 22, 2000

Hon. Commissioner of Patents
Washington, D.C. 20231

Sir:

REPLY/AMENDMENT/LETTER

This is a reply/amendment/letter in the above-identified application and includes the herewith attachment of same date and subject which is incorporated hereinto by reference and the signature below is treated as the signature to the attachment in absence of a signature thereto.

FEE REQUIREMENTS FOR CLAIMS AS AMENDED

1. Small Entity claim	Claims remaining after amendment	Highest number previously paid for	Present Extra	Large/Small Entity	Additional Fee	Fee Code Lg/Sm
A. <input checked="" type="checkbox"/> NOT made	54	**minus 54	0	x \$18/\$9 =	+ \$0	103/203
B. <input type="checkbox"/> Withdrawn	18	***minus 16	2	x \$84/\$42 =	+ \$168	102/202
C. <input type="checkbox"/> made herewith	4. If amendment enters proper multiple dependent claim(s) into this application for first time (leave blank if this is a reissue application) add + \$280/\$140 = + \$0 104/204					
D. <input type="checkbox"/> made previously	5. Original due Date: November 7, 2002 <input type="checkbox"/> NONE					
For B & C See Required Separate Paper (Pat-256)	6. Petition is hereby made to extend the original due date to cover the date this response is filed for which the requisite fee is attached					
	(1 mo)	\$110/\$55 =				115/215
	(2 mos)	\$400/\$200 =		+ \$0		116/216
	(3 mos)	\$920/\$460 =				117/217
	(4 mos)	\$1,440/\$720 =				118/218
	(5 mos)	\$1,960/\$980 =				128/228
	7. Enter any previous extension fee paid since above original due date and subtract - \$0					
	8. Extension Fee + \$0					
	9. If Terminal Disclaimer attached, add Rule 20(d) official fee + \$110/\$55 + \$0 148/248					
	10. If IDS attached requires Official Fee under Rule 97 (c), add + \$180 + \$0 126					
	or if Rule 97(d) Request add + \$180 + \$0 126					
	11. After-Final Request Fee per rules 129(a) and 17(r) add + \$740/370 + \$0 146/246					
	12. No. of additional inventions for examination per Rule 129(b) x \$740/370 ea + \$0 149/249					
	13. Request for Continued Examination (RCE) + \$740/370 + \$0 1179/1279					
	14. Petition fee for + \$0					
	TOTAL FEE = \$168					

PLEASE CHARGE
OUR DEP. ACCT

15.

16. *If the entry in this space is less than entry in next space, the "Present Extra" result is "0".

17. **If the "Highest number previously paid for" in this space is less than 20, write "20" in this space.

18. ***If the "Highest number previously paid for" in this space is less than 3, write "3" in this space.

Our Deposit Account No. 03-3975)
(Our Order No. 040258 0272798

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CHARGE STATEMENT: The Commissioner is hereby authorized to charge any fee specifically authorized hereafter, or any missing or insufficient fee(s) filed, or asserted to be filed, or which should have been filed herewith or concerning any paper filed hereafter, and which may be required under Rules 16-18 (missing or insufficiencies only) now or hereafter relative to this application and the resulting Official Document under Rule 20, or credit any overpayment, to our Accounting/Order Nos. shown above, for which purpose a duplicate copy of this sheet is attached.

This CHARGE STATEMENT does not authorize charge of the issue fee until/unless an issue fee transmittal sheet is filed.

Query: Is appeal deadline now? If so, file Notice of Appeals separately.

Pillsbury Winthrop LLP
Intellectual Property Group
By Atty: Glenn J. Perry

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Atty/Sec: gjp/KJ

NOTE: File this cover sheet in duplicate with PTO receipt (PAT-103A) and attachments

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION OF

Mitsuaki KOMINO *et al.*

Appln. No.: 09/667,770

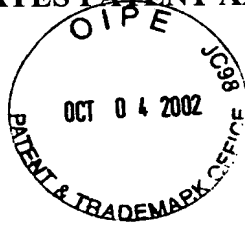
Filed: September 22, 2000

Title: PLASMA PROCESSING APPARATUS, AND ELECTRODE STRUCTURE AND
TABLE STRUCTURE OF PROCESSING APPARATUS

Confirmation No.: 8174

Group Art Unit: 1763

Examiner: R. Zervigon



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October 5, 2002

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AMENDMENT

Hon. Commissioner of Patents
Washington, D.C. 20231

Sir:

In response to the Office Action dated August 7, 2002, please amend the above
identified application as follows:

IN THE CLAIMS:

Kindly enter the following amended claims:

21. (Twice Amended) A placement table structure used for a processing apparatus
performing a predetermined process on an object to be processed in a process chamber in
which a vacuum can be formed, the placement table structure including:

a placement table having a heater unit therein so as to heat said object to be processed;

a cooling block joined to the placement table and having a cooling jacket which cools
said placement table;

a heat resistant metal seal member configured and arranged to seal a heat transfer
space formed between said placement table and said cooling block; and

heat transfer gas supply means constructed and arranged to supply a heat transfer gas
to said heat transfer space,

wherein a surface of said heat resistant metal seal member is covered by a soft metal
film made of a material having a softening point lower than a process temperature of said